IN THE CLAIMS

Please amend the claims as follows:

Claims 1-25 (Canceled).

Claim 26 (Currently Amended): A vapor deposition material comprising a polycrystalline body, a sintered body, or single crystal,

wherein the vapor deposition material is in the form of a pellet, having a surface wherein the pellet is entirely covered with a fluoride layer, and wherein the fluoride layer comprises a material of formula

 MO_XF_Y ,

wherein M is Mg, Ca, Sr, Ba, an alkali earth compound metal, a rare earth metal, or a compound metal of an alkali earth metal and rare earth metal, and 0 < X < 2 and $0 < Y \le 4$.

Claim 27 (Previously Presented): The vapor deposition material according to claim 26 wherein said polycrystalline body, sintered body, or single crystal is formed from one or more oxides selected from the group consisting of MgO, CaO, SrO, BaO, an alkaline earth composite oxide, a rare earth oxide, and a composite oxide of an alkaline earth oxide and a rare earth oxide.

Claim 28 (Previously Presented): The vapor deposition material according to claim 26, wherein said fluoride layer is obtained by reacting a fluoridation agent with one or more oxides selected from the group consisting of MgO, CaO, SrO, BaO, an alkaline earth composite oxide, a rare earth oxide, and a composite oxide of an alkaline earth oxide and a rare earth oxide.

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Claim 29 (Previously Presented): An FPD obtained by vapor depositing the vapor deposition material according to claim 26 onto a substrate.

Claim 30 (Previously Presented): The vapor deposition material according to Claim 26, wherein the fluoride layer is from 0.1 nm to 100 µm in thickness.

Claim 31 (Previously Presented): The vapor deposition material according to Claim 26, wherein the fluoride layer is from 1 nm to 1 µm in thickness.

Claim 32 (Canceled).

Claim 33 (Previously Presented): The vapor deposition material of Claim 26, comprising a polycrystalline body covered with a fluoride layer.

Claim 34 (Previously Presented): The vapor deposition material of Claim 26, comprising a sintered body covered with a fluoride layer.

Claim 35 (Previously Presented): The vapor deposition material of Claim 26, comprising a single crystal covered with a fluoride layer.

Claim 36 (Previously Presented): The vapor deposition material of Claim 26, wherein $0.25 \le X < 2$.

Claim 37 (Previously Presented): The vapor deposition material of Claim 26, wherein $0.5 \le X < 2$.

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Claim 38 (Previously Presented): The vapor deposition material of Claim 26, wherein $1 \le Y \le 4$.

Claim 39 (Previously Presented): The vapor deposition material of Claim 26, wherein the fluoride layer is a material selected from the group consisting of MO_{0.5}F, MO_{0.25}F_{1.25}, MOF₂, MOF, and MOF_{0.66}.

Claim 40 (Canceled).

Claim 41 (New): The vapor deposition material according to Claim 26, wherein the vapor deposition material is substantially non-reactive with CO₂ gas or H₂O gas.

Claim 42 (New): The vapor deposition material according to Claim 26, wherein the weight gain of the vapor deposition material after standing in air for seven days is 0.1% or less.

BASIS FOR THE AMENDMENT

Claims 26, 29-31, 33-39 and 41-42 are active in the present application. Claims 1-25, 27-28, 32 and 40 have been canceled. Independent Claim 26 has been amended to state that the vapor deposition material is in the form of a pellet. Support for the amendment is found throughout the specification, for example page 16, lines 1-3 and, for example, Example 33 where the sintered body is described as a pellet (page 40, lines 8-10). Independent Claim 26 has been further amended to include the limitations of previous dependent Claim 32. Claims 41 and 42 are new claims. Support for new dependent Claim 41 is found on page 7, lines 3-11. Support for new dependent Claim 42 is found in Table 1 on page 35. No new matter is added.